ZrMoN FILMS ON 304 STAINLESS STEEL AS Bipolar plates for PEMFCs USING PHYSICAL-VAPOR-DEPOSITION (PVD) TECHNOLOGY

ZrMoN PREVLEKE NA NERJAVNEM JEKLU 304 KOT BIPOLARNE PLOŠČE ZA PEMFC-je Z UPORABO TEHNOLOGIJE NANAŠANJA IZ PARNE FAZE (PVD)

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ZrMoN films were deposited on a 304 stainless-steel (SS304) substrate with a radio-frequency (RF) reactive magnetron-sputtering system and the properties were changed by adjusting the power of the Mo target. The corrosion behaviors of the ZrMoN films were investigated with potentiodynamic tests and electrochemical impedance spectroscopy (EIS) under the condition of an aerated 0.5M H2SO4 + 1.99 mg/L NaF solution at 70 °C. The results revealed that all samples with ZrMoN films have good hydrophobicity. The XRD test showed that the ZrMoN film is the substitutional solid solution of Mo atoms into ZrN films. As an overall evaluation, the power of the Mo target is 30W. A coated sample displays the best corrosion resistance in the cathode of the PEMFC environment when the power of the Mo target is considered, which indicates that with an increase of the power of the Mo target, the solid solubility also increases; but with a continuous increase of the Mo-target power, the solubility increases and a lattice distortion also occurs, leading to an increase in defects.

Keywords: ZrMoN, corrosion behavior, bipolar-plate material, physical-vapor-deposition technology (PVD)

1 INTRODUCTION

The whole world requires the pollution to be reduced due to the global warming, caused by greenhouse gases such as CO2, NOx and Sox.1,2 The proton-exchange-membrane fuel cell (PEMFC) is considered to be a competitive candidate as the next-generation power source for automotive, stationary and portable applications due to its prominent characteristics including a quick startup, zero emission, high efficiency, etc.3,4 It is a device that directly and efficiently converts chemical energy into electricity.5 One of the most expensive and heaviest components in a PEMFC stack is the bipolar plate (BPP).6 The BPP plays several important roles in the whole fuel-cell stack, affecting its total weight, volume and cost. In order to perform these functions, a BPP should feature high corrosion resistance in PEMFC environments, good electrical conductivity, high mechanical strength, high capability of gas separation, low cost and easily machining.7 Metallic BPPs have been widely accepted due to their good electrical conductivity, good mechanical properties, processing performance and low production cost. However, during the fuel-cell operating condition, a sample exposed to a highly acidic medium (pH2–3) containing ions like F–, SO42– and HCO3– undergoes severe corrosion on its surface, which results in a loss of the power output of the PEMFC.8

In general, transition-metal nitride films are chemically inert and thermally stable. However, an attack of the corrosive medium on the substrate is severe due to the defects within the film (such as micro-cracks, pores, pinholes, grain boundaries, etc.).9 These defects create a direct path between the exposed substrate and the corrosive medium, thus affecting the electrochemical behavior of these films. Among the large refractory-metal carbnitrides, ZrCN is an attractive material because of its excellent chemical and physical properties, such as a relatively low electrical resistivity and high corrosion resistance.10 Zr alloys undergo corrosion in high-temperature water and steam, with rapid initial corrosion forming an oxide layer which causes the oxidation rate to slow down. This is because the migration of charged species (oxygen ions and electrons) across the oxide thickness is inhibited. As corrosion progresses, a critical ox-
ide thickness is reached, at which the protection of the oxide layer breaks down and a rapid increase in the oxidation rate is observed. The breakdown is known as ‘the transition’ and it is followed by a reduction in the oxidation rate as a new protective oxide layer forms.\textsuperscript{12} Molybdenum (Mo) is considered as one of the principal alloying elements for stainless steels and its beneficial effects on the corrosion resistance were most thoroughly investigated.\textsuperscript{13–15} It is well known that Mo enhances the resistance to pitting corrosion and expands the passive region in sulfuric acid, making types 316 and 317 suitable for 90 % mass fractions of H\textsubscript{2}SO\textsubscript{4} at ambient temperature. The corrosion behavior of single-layer films like TiN and CrN was widely reported;\textsuperscript{16–18} however, very few studies reported on ZrMoN films.

In order to improve the corrosion resistance of metallic BPPs, many attempts were made by employing different surface-modification methods. The formation of a protective film on the BPPs with physical-vapor deposition (PVD) is proven to be an effective method and has been extensively studied.\textsuperscript{19–24} Many researchers focused on the multilayer, while fewer on the composite film. Thus, in this study, ZrMoN films were deposited on SS304 using an RF magnetron-sputtering system and the properties were changed by adjusting the power of the Mo target. The effects of the Mo-target power on the corrosion behavior were investigated by simulating the cathode environment of the PEMFC.

2 EXPERIMENTAL PART

2.1 ZrMoN films and electrode preparation

The substrate (a 15 mm diameter and 2 mm thickness) used was SS304 consisting of 0.08 % amount fraction of C, 1.00 % amount fraction of Si, 2.00 % amount fraction of Mn, 0.045 % amount fraction of P, 0.03 % amount fraction of S, 18–20.0 % amount fraction of Cr, 8.0–10.5 % amount fraction of Ni and Fe balance. ZrMoN films were deposited on the substrate surface using the PVD technology, and the properties were changed by adjusting the power of the Mo target. The film was deposited using an RF magnetron-sputtering system (JGP450, SKY Technology Development Co., Ltd., CAS, China), which consists of two RF sputtering guns, each of them mounted on water-cooled target holders. The distance between the substrate holder and the targets was 11 mm. The substrates were cleaned with successive rinsing in ultrasonic baths of deionized water, ethyl alcohol absolute (C\textsubscript{2}H\textsubscript{6}O = 99.7 %) and acetone and blown dry with dry air. The Zr target and the Mo target with the same purities of 99.9 % were positioned 11 mm from the substrate. Argon gas and nitrogen gas of very high purity (99.999 %) were introduced. The base pressure was less than 6.0×10\textsuperscript{–4} Pa. Prior to deposition, the targets were cleaned by pre-sputtering for 10 min, while the substrate was isolated from the plasma with a shutter. More parameters for the deposition of the ZrMoN films are listed in Table 1.

<table>
<thead>
<tr>
<th>Table 1: Deposition parameters for ZrMoN films</th>
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<tr>
<td>ZrMoN films</td>
</tr>
<tr>
<td>Base pressure</td>
</tr>
<tr>
<td>Total pressure</td>
</tr>
<tr>
<td>Flow rate of Ar and N\textsubscript{2}</td>
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<tr>
<td>Zr-target power (RF)</td>
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<tr>
<td>Mo-target power (RF)</td>
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<tr>
<td>Deposition temperature</td>
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<td>Deposition time</td>
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</table>

2.2 Contact-angle test

Wettability has a strong effect on the cell performance, particularly at high current densities. A high contact angle implies a high surface energy and low surface wettability of a material.\textsuperscript{25} Water contact angles (WCA) were measured using a drop shape analyzer (DSA) (JC2000D, Powereach Corporation, Shanghai, China). The volume of a water droplet was =4 \mu L and the average values of 10 measurements were reported as the water contact angle.

2.3 Structural characterization

The samples were sealed in rubber mud; XRD data of the films were reordered with SHIMADZU XRD-6000 ray diffraction (XRD, Cu-K\textsubscript{α} = 1). The working voltage and the current for the diffractometer were set at 40 kV and 30 mA, respectively. The scanning range (2\theta) was 20°–80°.

The thickness and surface morphology of the films were observed using JSM-6480 scanning electron microscopy.

2.4 Electrochemical corrosion test

The corrosion behavior of ZrMoN-coated and uncoated samples under the cathode of PEMFC were studied; the electrolyte was a 0.5M H\textsubscript{2}SO\textsubscript{4} + 2 mg/L NaF solution at 70 °C, and the air was bubbled through the test. A three-electrode electrochemical cell was used, together with a platinum counter electrode and an Hg/HgO saturated KCl electrode as the reference electrode. The sample to be tested was the working electrode. Samples were loaded in silicon rubber and the surface area exposed to the corrosive medium was approximately 0.25 cm\textsuperscript{2}. The samples were kept in the test solution for a period of time before the potentiodynamic polarization study in order to establish the open-circuit potential (E\textsubscript{ocp}) or the steady-state potential.\textsuperscript{26}

2.4.1 Potentiodynamic polarization

The sweep range was –0.4 V–1.5 V (relative to the E\textsubscript{ocp}) and the sweep rate was 1mv/s. Tafel plots were obtained after the electrochemical measurements. The corrosion potential (E\textsubscript{corr}) and the corrosion-current density (i\textsubscript{corr}) were deduced from the Tafel plots (that is, log i vs. E plot). The polarization resistance (R\textsubscript{p}) was measured.
using linear sweep voltammetry and calculated from the Stern-Geary equation, with Equation (1):27

\[ R_p = 2.303 i_{corr} \left( \frac{1}{b_a} + \frac{1}{b_c} \right) \]  

(1)

\( R_p \) in Equation (1) relates to the corrosion behavior of the test materials; the \( i_{corr} \) and the Tafel constants \( b_a \) and \( b_c \) can be measured from the experimental data. The Tafel constant \( b_c \) is negative; its absolute value was used in Equation (1).

2.4.2 Electrochemical impedance spectroscopy

The impedance measurements were made at the open-circuit potential and the applied alternating potential had an amplitude of 10 mV. The spectrum was recorded in a frequency range of 10 mHz~100 KH. After each experiment, the impedance data was displayed as Nyquist plots. The Nyquist plot is a plot of the real (\( Z' \)) vs. imaginary impedance (\( Z'' \)). From this plot at a high frequency, the value of the solution resistance (\( R_s \)) was obtained and at a low frequency, the charge transfer resistance (\( R_t \)) was deduced. The data were analyzed using the Zview software.

3 RESULTS AND DISCUSSION

3.1 Contact-angle test

Table 2 shows the contact angles of the ZrMoN coated samples with water. Due to the liquid water, the battery cannot be discharged in time and the water enters the porous electrode blocking the reaction gas path and reducing the catalytic activity area. This results in a decreased cell performance, and the liquid water attached to the surfaces of the metallic bipolar plates accelerates the corrosion of the bipolar plates.28 So, the bipolar-plate material should have low surface wettability. On Table 2, the contact angles are nearly 90°. It is obvious that the ZrMoN coated samples have high contact angles on the surfaces, which shows good hydrophobicity.

<table>
<thead>
<tr>
<th>Films</th>
<th>Contact angle</th>
</tr>
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<tbody>
<tr>
<td>P(Mo)=20W</td>
<td>96.11°</td>
</tr>
<tr>
<td>P(Mo)=30W</td>
<td>94.45°</td>
</tr>
<tr>
<td>P(Mo)=50W</td>
<td>97.61°</td>
</tr>
<tr>
<td>P(Mo)=90W</td>
<td>93.83°</td>
</tr>
</tbody>
</table>

3.2 XRD test

Crystal phases of the ZrMoN coated samples were analyzed with XRD patterns and the results are presented in Figure 1. This figure shows that the films mainly include ZrN phases; there are no MoN and Mo phases in the films, and it is obvious that a ZrMoN film is the substitutional solid solution of Mo atoms into ZrN films. The XRD patterns show that there are two main diffraction peaks, a (1 1 1) peak and a (2 2 2) peak. The (1 1 1) peak is the strongest; therefore, the growth orientation of the ZrMoN film is mainly in the (1 1 1) direction.

3.3 SEM analysis

Figure 2 is a SEM micrograph of the ZrMoN film where the Mo-target power is 20 W. The formation of pinholes is nearly impossible to avoid. This is because the coated surfaces are always non-uniform and because the coating tends to grow in a non-uniform manner. Various growth models were developed to describe the growth process.29 A general feature of these models is the fact that after the original nucleation stage, the growth takes place in isolated islands, which then grow together, leaving the voids between them. The general growth morphology of the coatings is typically columnar. Although various techniques can be used to minimize the number of pinholes, they usually cannot be totally eliminated. They occur commonly in all kinds of coatings on all kinds of substrates.30

Figure 1: XRD test results for ZrMoN films

Figure 2: SEM micrograph of the ZrMoN film where the power of Mo target is 20 W
In this study, the coating layers also had such defects, arising from the coating process or the substrate, although relatively dense coatings were obtained. A SEM micrograph of the defects in the coating layer of the ZrMoN film is given in Figure 2. It can be clearly seen from Figure 2 that there is a pinhole in the film, shown as a black hole, due to the columnar growth during the coating process. It is indicated that the electrolyte may penetrate through the pores and the micro-pores in the film to the substrate, causing corrosion.

3.4 Potentiodynamic tests

Table 3 shows the $E_{ocp}$ values of the ZrMoN coated and uncoated samples. Except for the sample with 20 W, the $E_{ocp}$ values for the samples with a higher Mo-target power are higher than that of the uncoated sample, showing a better corrosion resistance than the uncoated sample. Figure 4 shows potentiodynamic polarization curves of the ZrMoN coated and uncoated samples in a simulated PEMFC working solution. Table 4 lists polarization parameters of the ZrMoN coated and uncoated samples.

As mentioned earlier, the formation of coating defects is almost impossible to avoid totally. Consequently,
when subjected to a corrosive atmosphere, coated samples form galvanic cells at the defects near the interface due to an electrochemical difference between the ZrMoN film and the substrate. Once aggressive ions such as SO$_4^{2-}$ penetrate the film through these small channels, driven by capillary forces, the area is exposed to anodic dissolution, which usually extends laterally along the interface between the film and the substrate. Finally, the formed pits link up with each other, causing a removal of the entire coating by flaking,$^{35}$ which causes the above-mentioned corrosion process. As an overall evaluation, the power of the Mo target is 30 W. The coated sample displays the best corrosion resistance in the cathode of the PEMFC environment when the power of the Mo target is considered.

### 3.5 EIS tests

Figures 5 and 6 show the Nyquist and Bode plots for the ZrMoN coated and uncoated samples. The EIS data are displayed in Table 6. The Nyquist plots (Figure 5) show the presence of a single semicircle for the ZrMoN coated samples, which may be attributed to the short exposure time in the corrosive medium. The Bode plots (Figure 5a) show that the absolute impedance increases in the same order. Figure 5b shows that the phase angles of all the samples are nearly 80°. In this study, the equivalent-circuit diagram used in the experiment is shown in Figure 7.$^{26}$ The equivalent circuit for the uncoated sample is shown in Figure 7a. It consists of a double layer capacitance ($Q_{dl}$), which is parallel to the charge transfer resistance ($R_{ct}$); both of them are associated with the solution resistance ($R_s$) between the working electrode (WE) and the tip of the Luggin capillary. $Q$ stands for the constant phase element, which accounts for the deviations from the ideal dielectric behavior related to surface inhomogeneities. The value of $n$ is obtained from the slope of the log |Z| vs. log $f$ plot. The phase angle ($\theta$) can vary between 90° (for a perfect capacitor ($n = 1$)) and 0° (for a perfect resistor ($n = 0$)). In the present study, it represents a somewhat leaky capacitor with $n = 0.85$. The $C_{dl}$ is, therefore, replaced with the constant phase element when $n < 1$.

The CDC for the equivalent circuit proposed for a mild steel substrate is $R(QR)$. The proposed equivalent circuit for the PVD coating on the steel substrate with defects is shown in Figure 7b. Due to the low film thickness, when the coated sample is immersed in the electrolyte, the corrosion is expected to initiate rapidly at the pores present in the film. This leads to the formation of localized galvanic cells, which dominate the galvanic corrosion process.$^{19}$ In such cases, the electrochemical interface can be divided into the sub-interface electrolyte/coating and the electrolyte/substrate. For the EIS data simulation, the equivalent-circuit model for the coated samples proposed by V. K. William Grips$^{26}$ is used in this study, describing the mechanism of an electrochemical reaction. Therefore, the electrolyte can penetrate through the coating and attack the steel substrate. As the experiments are bubbled with air, the corrosion rate is limited by the slow diffusion of the electrolyte and oxygen through the defects in the film. This behavior can be described using a finite-length diffusion process.

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**Figure 5:** Impedance spectra of samples with ZrMoN films and substrate

**Figure 6:** a) Bode plots (log |Z| vs. log $f$) of samples with ZrMoN films and substrate, b) Bode plots (phase angle vs. log $f$) of samples with ZrMoN films and substrate
Therefore, the cotangent diffusion element \((O)\) should be adopted in series with the charge-transfer resistance.

In Figure 6b, the CDC is \(R(Q(R(Q(RO))))\). The capacitance \((Q_{\text{lim}})\) and the charge-transfer resistance for the porosity of the film \((R_{\text{pore}})\) are included as additional elements to the equivalent circuit, as shown for the substrate in Figure 7a. From the EIS data given in Table 6, the \(R_{\text{ct}}\) increases in the following order: 20 W, 90 W, uncoated, 50 W, 30 W. This indicates that the samples with a higher Mo-target power show a better corrosion resistance. With the increase of the power of the Mo target, the solid solubility also increases. When the power of the Mo target is 30 W, the solid solubility also increases. However, with a continuous increase of the Mo-target power, the solid solubility increases and a lattice distortion also occurs, leading also to an increase in defects. Through the study of PEMFC bipolar-plate materials, ZrMoN-coated stainless steel can be proven as a good candidate.

Acknowledgement

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5 REFERENCES


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